Special Issue

Monitoring and Control of Processes in the Context of Industry 4.0

Message from the Guest Editors

This Special Issue, titled "Monitoring and Control of Processes in the Context of Industry 4.0", aims to highlight the novel advances in process monitoring and control according to Industry 4.0 requirements. Topics will include, but are not limited to:

- The real-time monitoring of processes;
- Advanced control of processes using soft computing;
- Digitalization of processes, interfaces and digital twins:
- Smart sensors and smart metering in processes and signal processing;
- Vision and measuring systems for quality control;
- Data acquisition, storage and processing;
- Virtual, augmented and mixed reality in processes.

Guest Editors

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Dr. Sławomir Luściński

Deadline for manuscript submissions

closed (20 May 2024)



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About the Journal

Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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